Supporting Information

Highly Efficient and Stable CsPbBr₃ Perovskite Quantum Dots by Encapsulating in Dual-Shell Hollow Silica Spheres for WLEDs

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Figures and Tables Content

Figure S1	Page 2
Figure S2	Page 3
Figure S3	Page 4
Figure S4	Page 5
Figure S5	Page 6
Figure S6	Page 7
Figure S7	Page 8
Figure S8	Page 9
Figure S9	.Page 10
Figure S10	Page 11
Figure S11	Page 12
Figure S12	Page 13
Figure S13	Page 14
Figure S14	Page 15
Table S1	Page 16
Table S2	Page 16



Figure S1. The stepwise fabrication process of dual-shell hollow SiO_2 spheres via a simple successive ionic layer adsorption and reaction (SILAR) method.



Figure S2. (a) The SEM images of presynthesized PS spheres. (b) The size distribution of PS spheres with an average size of 133 nm.



Figure S3. (a) The SEM and (b) TEM images of as-prepared SiO_2 -2 spheres. (b) The size distribution of SiO_2 -2 spheres with an average size of 110 nm.



Figure S4. The FTIR spectra of PS, PS@NH₂-SiO₂, PS@NH₂-SiO₂@SiO₂ and NH₂-SiO₂@SiO₂.



Figure S5. The photographs of SiO₂-0 (left) and SiO₂-2 (right) aqueous solution with adsorption of Pb^{2+} for 20 min.



Figure S6. The zeta potential analysis of SiO₂-0 and SiO₂-2.



Figure S7. High-resolution XPS spectra of Si 2p.



Figure S8. The FTIR spectra of CPB-0, CPB-2, CPB-5 and CPB-10.



Figure S9. TEM images of (a) CPB-0, (b) CPB-2, (c) CPB-5 and (d) CPB-10.



Figure S10. The (a) PL spectra (black line), absorption spectra (red line) and (b) TEM image of pure CsPbBr₃ QDs.

It could be observed that the emission peak of pure CsPbBr₃ QDs is 516 nm and the absorption edges lock at 510 nm. The emission peak of pure CsPbBr₃ QDs keeps the same with amino-free CPB-0, but is slight red shift for CPB-2, CPB-5 and CPB-10, which demonstrate the passivation effect of amino-groups may hinder the growth of CsPbBr₃ QDs. The TEM images of pure CsPbBr₃ QDs shown in Figure S10b indicate a lattice distance of 0.58 nm, which corresponding to (100) plane of cubic CsPbBr₃ QDs.



Figure S11. The photographs of CPB-0, CPB-2, CPB-5 and CPB-10 under daylight (top) and UV light (bottom).



Figure S12. The Guassian fitting peaks of CPB-10.



Figure S13. Temperature dependent PL intensity of pure CPB (left) and CPB-2 (right) at different wavelengths.



Figure S14. Temperature dependent PL spectra of CPB-2 ranging from 20 to 190°C.

Time/mi n	SiO ₂ -0		SiO ₂ -2		
	measured value/(µg/mL)	adsorption percentage/%	measured value/(µg/mL)	adsorption percentage/%	
0	25	0	25	0	
5	24.0374	3.8504	21.4582	14.1672	
10	23.3292	6.6832	18.6433	25.4268	
20	22.6526	9.3896	15.8864	36.4544	
30	22.2281	11.0876	15.4642	38.1432	
40	22.0236	11.9056	15.5222	37.9112	
50	21.9869	12.0524	15.4397	38.2412	
60	22.0018	11.9254	15.4551	38.1796	

Table S1. The measured values of Pb^{2+} concentrations and calculated adsorption percentage of SiO₂-0 and SiO₂-2 with various time intervals.

Table S2. The optical characters of CPB-0, CPB-2, CPB-5 and CPB-10.

Samples	Absorption	PL	FWHM/nm	PLQY/%	Abs	$\tau_{avg}\!/\!ns$
	peak/nm	peak/nm				
CPB-0	(456, 513)	516	35	58.5	0.596	7.53
CPB-2	(449, 485)	512	41	88.9	0.602	11.61
CPB-5	(408, 472)	504	29	32.0	0.652	9.35
CPB-10	(424, 472)	504	32	31.3	0.398	5.58